Webinar









Laser Illuminated Maskless h-line Lithography

Join us for a Webinar on Wed, Jul 8, 2015 1:00P EDT

Power Technology will present new options for h-line lithography. Laser light sources have become a viable alternative to LED illuminated maskless lithography systems. Laser technology has several key advantages that promote throughput and increase production rates. This advantage is most visible at higher optical power levels.

Walter Burgess, VP of Sales & Engineering at Power Technology, Inc., is a Central Arkansas native with over 18 years of experience in the laser and photonics industry. Walter's managerial responsibilities include technical direction, product design, production commercialization, overseeing team performance, developing and managing relationships with key customers, managing the sales process from implementation through closing, and P&L responsibility.

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